



PATENT .

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	Raaijmakers et al.) Group Art Onit Onknown
Appl. No.	:	Unknown)
Filed	:	Herewith)
For	:	METHOD OF DEPOSITING SILICON WITH HIGH STEP COVERAGE)))
Examiner	:	Unknown)

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents Washington, D.C. 20231

Dear Sir:

Prior to examination on the merits, please amend the above-captioned application as indicated below.

IN THE SPECIFICATION

On page 1, after the title, insert the following heading and paragraph:

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-- Reference to Related Applications

Took 6232106

The present application is a divisional of U.S. Patent Application No. 09/264,167 filed March 5, 1999, which claims the priority benefit under 35 U.S.C. § 119(e) for provisional Application No. 60/077.082 filed March 6, 1998.--

IN THE CLAIMS

Please cancel Claims 1-32.